

Design of Three-Dimensional Optical Circuit Devices by Using Topology Optimization Method with Function-Expansion-Based Refractive Index Distribution

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Abstract—We extend topology optimization method with function-expansion-based refractive index distribution to optimization for three-dimensional optical circuits, in which a refractive index distribution in a design region is expressed by an expansion with some analytical functions. Three-branch optical waveguides have been optimized as numerical examples. Equally branching three-branch waveguides are achieved using our method. A limitation of topology optimization in two dimensions and dependency of initial structure are also shown.

Index Terms—Finite-element method, three-dimensional analysis, optical waveguide, topology optimization.

I. INTRODUCTION

IN the recent progress of optical communication systems, many kinds of high-performance and compact optical waveguide devices have been developed. Especially, silicon nanophotonic waveguides have great possibility to realize such devices, and extensive researches on these waveguides are being carried out.

Recently, topology optimization methods have begun to be used to realize high-performance microwave and photonic waveguide devices [1]-[12]. These methods can simultaneously deal not only with geometric form but also with topological configuration, so we can find out optimum structures that realize desired transmission characteristics.

In topology optimization, the density method was widely used to express refractive index distribution [1]-[3]. However, the topology optimization using the density method had a drawback: it creates gray areas, which had intermediate refractive index between those of materials used in a waveguide. This drawback results in optimized structures that are difficult to fabricate.

To suppress the gray areas, two types of approaches have been investigated; one is a density filtering technique [13], which has also been applied to optimization for optical devices

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such as photonic crystals [4]-[7], periodic grating surfaces [8], and plasmonic and dielectric structures [9], and the other is a technique based on a projection scheme using Heaviside function [14]. The latter can be classified into two schemes; one is the geometry projection method [10] and the other is the topology optimization method with function-expansion-based refractive index distribution [11], [12], and both have been applied to optimization for optical waveguide devices. However, these previous works were carried out in two dimensions. The limitations of optimization for optical circuits in two dimensions have not been unveiled.

In this paper, the topology optimization method with function-expansion-based refractive index distribution is extended to optimization for three-dimensional optical circuits. As numerical examples, the proposed method is applied to three-branch waveguides. We will see that an equally branching three-branch waveguide is successfully achieved using the proposed method, but that topology optimization in two dimensions fails to design three-dimensional three-branch waveguides.

In Section II, we review formulations of the proposed method. A few numerical results are shown in Section III. Section IV is the conclusion.

II. TOPOLOGY OPTIMIZATION

A. Representation of Refractive Index Distribution in Design Region

As an example, we consider a three-dimensional three-branch optical waveguide consisting of two materials with refractive indices of n_1 and n_2 , as shown in Fig. 1. The computational region is surrounded by the perfectly matched layer (PML) [15]-[17]. A refractive index distribution in the design region of size W_x by W_z is topology optimized so that optical power input from port 1 equally branches into ports 2 to 4.

In this paper, the refractive index distribution in the design region is expressed as follows [11]:

$$n^2(x, y, z) = n_1^2 + (n_2^2 - n_1^2)H(w(x, y, z)) \quad (1)$$

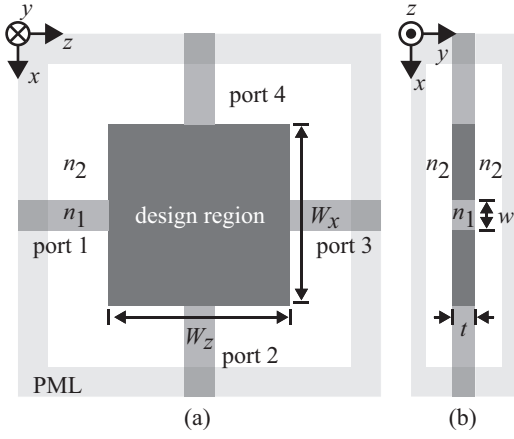


Fig. 1. Three-branch optical waveguide to be topology optimized: (a) top and (b) side views.

$$H(w) = \begin{cases} 0 & (w \leq -h) \\ \frac{1}{2} \left(\frac{w+h}{h} \right)^2 & (-h < w < 0) \\ 1 - \frac{1}{2} \left(\frac{w-h}{h} \right)^2 & (0 \leq w < h) \\ 1 & (w \geq h) \end{cases} \quad (2)$$

where $w(x, y, z)$ is some function to determine the refractive index distribution. The function $H(w)$ is used to convert a continuous value of $w(x, y, z)$ into either n_1 or n_2 . Since $H(w)$ must be differentiable in the sensitivity analysis described below, $H(w)$ has a transition region of width $2h$. The value of h can be either fixed or variable through the optimization process. After the optimization process is converged, h is reduced to zero to obtain an index distribution without gray area.

For $w(x, y, z)$, we employ the following sinusoidal-function-based expression:

$$w(x, y, z) = \sum_{i=0}^{N_x-1} \sum_{j=-N_z}^{N_z-1} (a_{ij} \cos \theta_{ij} + b_{ij} \sin \theta_{ij}) \quad (3)$$

$$\theta_{ij} = \frac{2\pi i}{L_x}(x - x_0) + \frac{2\pi j}{L_z}(z - z_0) \quad (4)$$

where N_x and $2N_z$ are the numbers of the expansion functions along the x - and z -directions, respectively, a_{ij} and b_{ij} , which are normalized as $\max(|w(x, y, z)|) = 1$, are the expansion coefficients, and x_0 and z_0 are the x - and z -coordinates of a given point in the computational region, respectively. Here, L_x and L_z are set to be greater than W_x and W_z , respectively. To ensure the feasibility of optimized structures, $w(x, y, z)$ is assumed to be constant with respect to y so that the refractive-index-distribution in the design region will be invariant in depth.

B. Finite Element Method

Since evaluation of characteristics of a given optical device is necessary in topology optimization, the three-dimensional finite element method (FEM) using tetrahedral edge elements for a waveguide discontinuity problem [18] is employed to

estimate the transmission characteristics. Applying the FEM, we obtain a final matrix equation as follows:

$$[P]\{\Phi\} = \{\Psi\}_\Gamma \quad (5)$$

where $[P]$ is a finite element matrix, $\{\Phi\}$ is an edge value vector of unknown electric/magnetic field, and $\{\Psi\}_\Gamma$ is a vector related to quantities on the incident plane. These matrix and vectors are described in detail in [18], [19].

For this example, a quarter of the solution domain is analyzed due to symmetry in the x - and y -directions.

C. Sensitivity Analysis

In the topology optimization, we need to know the dependence of transmission characteristics on the expansion coefficients a_{ij} and b_{ij} in (3). The transmission characteristics are represented by scattering parameters S_{n1} ($n = 1, \dots, N$) given as follows:

$$S_{n1} = -\delta_{n1} + \{g_n\}^T \{\Phi\} \quad (6)$$

where δ_{n1} represents the Kronecker delta, $\{g_n\}$ is a known vector related to a propagating mode in port n , N is the number of ports, and superscript T denotes a transpose.

To calculate the dependence of S_{n1} on a_{ij} or b_{ij} , the adjoint variable method (AVM) [3]-[12], [20]-[25] is used. Let C be an objective function to be minimized subject to the constraint (5). Here we define C as

$$C = F(|S_{11}|, |S_{21}|, \dots, |S_{N1}|) \quad (7)$$

where F stands for a function with respect to $|S_{11}|, |S_{21}|, \dots, |S_{N1}|$. We rewrite the objective function by adding the zero function:

$$\tilde{C} = F(|S_{11}|, |S_{21}|, \dots, |S_{N1}|) - \text{Re} [\{\gamma\}^T ([P]\{\Phi\} - \{\Psi\}_\Gamma)] \quad (8)$$

where $\{\gamma\}$ is any arbitrary complex vector. From (8), we obtain that

$$\frac{\partial \tilde{C}}{\partial c_{ij}} = \text{Re} \left[\left(\sum_{n=1}^N \frac{\partial F}{\partial |S_{n1}|} \frac{S_{n1}^*}{|S_{n1}|} \{g_n\}^T - \{\gamma\}^T [P] \right) \frac{\partial \{\Phi\}}{\partial c_{ij}} - \{\gamma\}^T \frac{\partial [P]}{\partial c_{ij}} \{\Phi\} \right] \quad (9)$$

where c_{ij} is a_{ij} or b_{ij} , and $*$ denotes complex conjugate. In turn, this can be written as

$$\frac{\partial \tilde{C}}{\partial c_{ij}} = -\text{Re} \left[\{\gamma\}^T \frac{\partial [P]}{\partial c_{ij}} \{\Phi\} \right] \quad (10)$$

when $\{\gamma\}$ satisfies the adjoint equation:

$$[P]^T \{\gamma\} = \sum_{n=1}^N \frac{\partial F}{\partial |S_{n1}|} \frac{S_{n1}^*}{|S_{n1}|} \{g_n\}. \quad (11)$$

After the sensitivity analysis, a_{ij} and b_{ij} are updated using the hill climbing method.

III. NUMERICAL RESULTS

As numerical examples of the proposed design method, we consider the three-branch optical waveguide, as shown in Fig. 1. The refractive indices of core and cladding are $n_1 = 3.4$ and $n_2 = 1.45$, respectively. The waveguide width is $w = 0.4 \mu\text{m}$, the design-region width in x - and z -directions are, respectively, $W_x = W_z = 2 \mu\text{m}$. Both the waveguide and design-region thicknesses are $t = 0.2 \mu\text{m}$. For (3) and (4), $N_x = N_z = 16$, and $L_x = L_z = 2.4 \mu\text{m}$, where the dependence of $N_x (= N_z)$ on the optimization is demonstrated in Fig. 7 of [12]. Although the increasing numbers of N_x and N_z may improve the circuit performance, the degree of freedom in optimization also increases. This will cause fragment patterns in the design region, which decrease the feasibility of the circuits, and slow convergence on optimization. As we will see below in this section, the optimized circuits show acceptable performances with $N_x = N_z = 16$. The operation wavelength is $\lambda = 1.55 \mu\text{m}$. The fundamental E^x mode is launched into port 1. The objective function to be minimized is given as follows:

$$C = 1 - \sum_{n=2}^4 |S_{n1}|^2 + \left| \frac{|S_{21}|^2 + |S_{41}|^2}{2} - |S_{31}|^2 \right|. \quad (12)$$

We demonstrate optimum design of the three-branch waveguide in three ways. Each is described below.

A. Two-dimensional optimization with fixed h and its three-dimensional analysis

First, we consider three-dimensional analysis for a three-branch waveguide obtained by the two-dimensional topology optimization [3]. To construct the three-dimensional model, the optimized structure in two dimensions is thickened to t . In this optimization, the value of h in (2) is fixed to 0.005. We will see that topology optimization in three dimensions is necessary.

The results for two-dimensional topology optimization are shown in Figs. 2 and 3. The effective index method is applied to obtain the two-dimensional model, thus refractive indices of the core and cladding are 2.70332 and 1.45, respectively. Fig. 2 shows the initial and optimized structures together with propagating field distributions. The normalized power as a function of iteration count is shown in Fig. 3. The optimum structure is obtained at the 193rd iteration. The normalized output powers are $|S_{21}|^2 = 0.322$, $|S_{31}|^2 = 0.332$, and $|S_{41}|^2 = 0.322$. We can see that optical power is almost equally branched, and that the transmission characteristics are drastically improved through the optimization. Note that, in this section, the resulting normalized output power is the one for the optimized structures before the elimination of gray area. We will see in Subsection III-C that the effect caused by the elimination of gray area can be negligible.

However, the propagating field distribution in the three-dimensional model built from Fig. 2 (b) is shown in Fig. 4. The normalized output power are $|S_{21}|^2 = |S_{41}|^2 = 0.019$ and $|S_{31}|^2 = 0.441$. In the three-dimensional analysis, the computational region was reduced to quarter because of the symmetry, as a result $|S_{21}|^2 = |S_{41}|^2$. The transmission

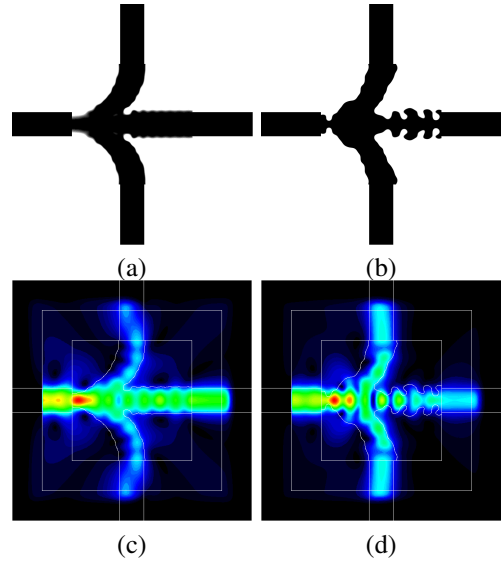


Fig. 2. Two-dimensional topology optimization for the three-branch waveguide: (a) the initial, and (b) the optimized structures, propagating field in (c) the initial and (d) the optimized structures.

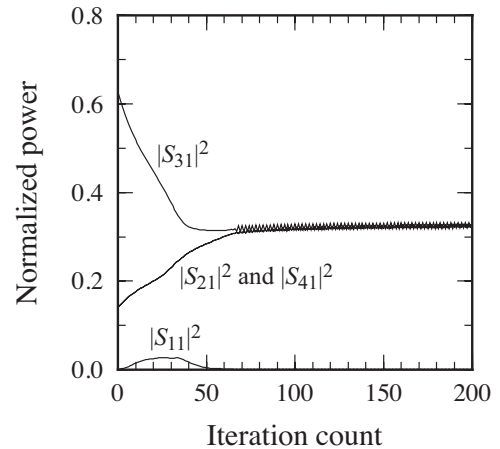


Fig. 3. Normalized power as a function of iteration count for topology optimization in two dimensions. The optimum structure is obtained at the 193rd iteration. It is noted that the curves for $|S_{21}|^2$ and $|S_{41}|^2$ are overlapped.

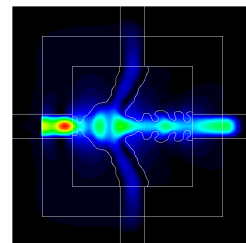


Fig. 4. Propagating field in the three-dimensional three-branch waveguide, where the optimum structure obtained by the two-dimensional optimization is thickened to $t = 0.2 \mu\text{m}$.

characteristics of the three-dimensional model is obviously deteriorated. Thus topology optimization for three-dimensional optical circuits is necessary.

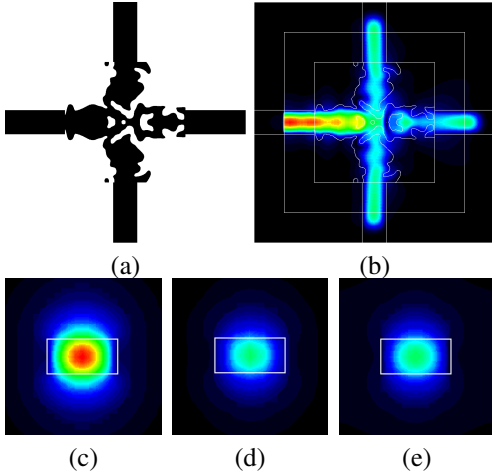


Fig. 5. Numerical results for the topology optimization with a fixed value of h . (a) The optimized structure. (b) Top view of propagating field distribution. Cross-sectional views of propagating field distributions at (c) port 1, (d) port 2 and 4 [because of the symmetry], and (e) port 3.

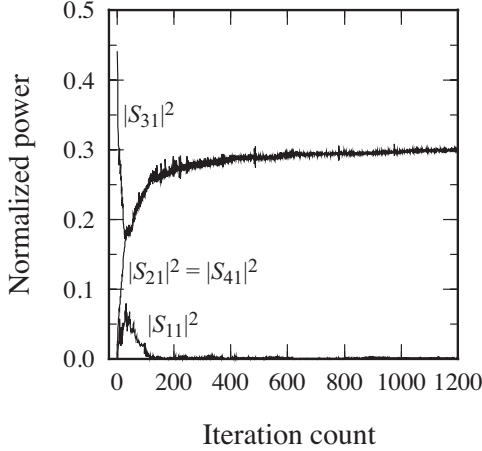


Fig. 6. Normalized power as a function of iteration count for topology optimization with a fixed value of h . The optimum structure is obtained at the 1198th iteration. We note that $|S_{21}|^2 = |S_{41}|^2$ because of the symmetry.

B. Optimization for three-dimensional optical circuits with fixed h

In this subsection, the three-dimensional three-branch waveguide is optimized. The two-dimensionally optimized waveguide shown in Fig. 2 (b) is taken as the initial structure to reduce the computational time. The computational region is reduced because of the symmetry. Here, the value of h is fixed to 0.005.

The optimized structure and propagating field distributions in it are shown in Fig. 5, and normalized power as a function of iteration count is shown in Fig. 6. The optimum structure was obtained at the 1198th iteration, and its normalized output powers are $|S_{21}|^2 = |S_{41}|^2 = 0.322$ and $|S_{31}|^2 = 0.332$. We can see that the transmission characteristics are much improved by using the three-dimensional topology optimization.

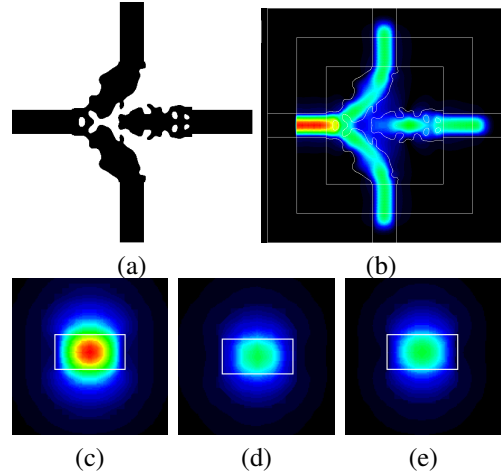


Fig. 7. Numerical results for the topology optimization with variable value of h . (a) The optimum structure. (b) Top view of propagating field distribution. Cross-sectional views of propagating field distributions at (c) port 1, (d) port 2 and 4 [because of the symmetry], and (e) port 3.

C. Optimization for three-dimensional optical circuits variable h

Next, we consider topology optimization of the three-dimensional three-branch waveguide in the same way as the previous subsection, but the value of h is renewed as a monotonically decreasing function of iteration count n like a decreasing radius of density filter [9], as follows:

$$h = 2 \exp(-n/200). \quad (13)$$

The optimized structure and propagating field distributions in it are shown in Fig. 7, and normalized power as a function of iteration count is shown in Fig. 8. The optimum structure was obtained at the 1161st iteration, and its normalized output powers are $|S_{21}|^2 = |S_{31}|^2 = |S_{41}|^2 = 0.325$. An equally branching three-branch waveguide is obtained. We think that the better solution than the one in the previous subsection has been obtained because of higher degree of freedom for modification of the structure in early step of the optimization due to larger gray area.

The optimized structures before the elimination of gray area for Fig. 7 (a) is shown in Fig. 9. The gray area, which occupies only 0.63% of area of the design region, is painted in red. The normalized output power shown above is for a structure with gray area. After the elimination of gray area [Fig. 7 (a)], the normalized output powers become $|S_{21}|^2 = |S_{41}|^2 = 0.3248$ and $|S_{31}|^2 = 0.3251$. The difference by the elimination of gray area can be negligible.

D. Initial-structure dependency

Finally, we consider initial-structure dependency on the topology optimization.

The three-branch optical waveguide is optimized with a simpler initial structure as shown in Fig. 10 (a), where the design region has a constant refractive index of 2.921. Here, optimization with a fixed value of h of 0.005 for a three-dimensional optical circuit is carried out from the start. The optimum structure is obtained at the 196th iteration as shown

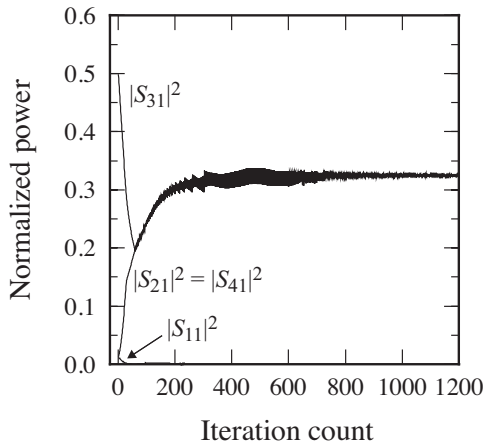


Fig. 8. Normalized power as a function of iteration count for topology optimization with variable value of h given as (13). The optimum structure is obtained at the 1161st iteration. We note that $|S_{21}|^2 = |S_{41}|^2$ because of the symmetry.

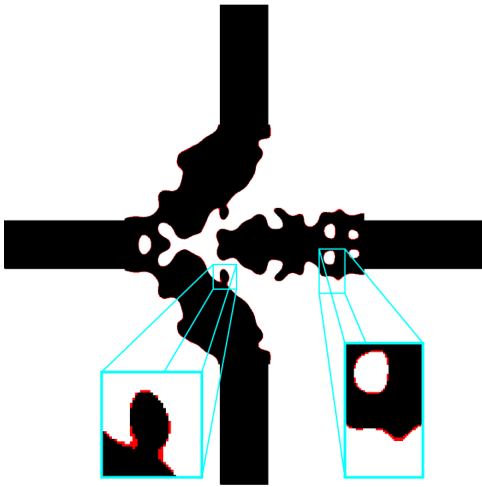


Fig. 9. The optimized structure before the elimination of gray area for Fig. 7 (a). The gray area, which occupies 0.63% of area of the design region, is painted in red. Insets are magnified refractive index distributions.

in Fig. 10 (b), and propagating field in it is shown in Fig. 10 (c). Here, its normalized output powers are $|S_{21}|^2 = |S_{41}|^2 = 0.241$ and $|S_{31}|^2 = 0.338$.

In comparison with the previous results, we can see that the optimized results strongly depend on initial structures. We think that there are a lot of local optima due to a high-index-contrast waveguide structure, and that the result was trapped in one of them. Thus an initial structure with a starting guess is needed for successful convergence to optimize high-index-contrast waveguide structures for the suggested topology optimization approach.

IV. CONCLUSION

We extended the topology optimization method with function-expansion-based refractive index distribution to optimization for three-dimensional optical circuits. The proposed method was applied to design equally branching three-branch waveguides, and it has been achieved. We have also found out

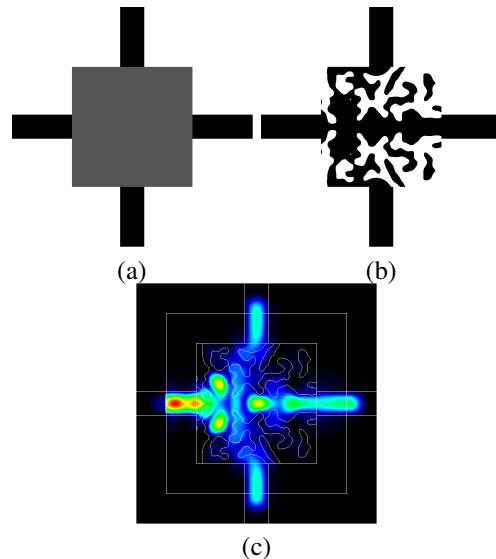


Fig. 10. Numerical results for the topology optimization for the three-dimensional optical circuit with a simple initial structure: (a) the initial and (b) optimized structures, and (c) propagating field in the optimized structure.

that the optimization for a three-dimensional optical circuit is necessary for optimum design of three-dimensional waveguides.

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